			AIC
	Application No.	Applicant(s)	
Notice of Allowshills	10/616,180	SASAKI ET AL.	
Notice of Allowability	Examiner	Art Unit	
	Joseph L. Williams	2879	
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.			
1. This communication is responsive to <u>7/9/03</u> .			
2. ☑ The allowed claim(s) is/are <u>2-5 and 12-15</u> .			
3. X The drawings filed on <u>09 July 2003</u> are accepted by the Examiner.			
4.			
Attachment(s) 1. ☐ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 7/9/03 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	5. Notice of Informal P 6. Interview Summary Paper No./Mail Dat 8), 7. Examiner's Amenda 8. Examiner's Stateme 9. Other	(PTO-413), e nent/Comment	

Application/Control Number: 10/616,180 Page 2

Art Unit: 2879

DETAILED ACTION

Priority

1. Acknowledgment is made of applicant's claim for foreign priority under 35 U.S.C. 119(a)-(d). The certified copy has been filed in parent Application No. 09/869,866, filed on 05 July 2001. *Allowable Subject Matter*

2. Claims 2-5 and 12-15 are allowed.

The following is an examiner's statement of reasons for allowance: Regarding independent claim 2, the prior art of record neither shows nor suggest any method of manufacturing of a gas discharge panel wherein a first substrate was placed under a reduced pressure and heated in a first reduced pressure chamber, and/or the second substrate was placed under a reduced pressure and heated in a second reduced pressure chamber prior to an alignment step in which the first and second substrates were aligned under a reduced pressure in a third reduced pressure chamber.

Regarding independent claim 13, the prior art of record neither shows nor suggest manufacturing apparatus for a gas discharge panel having a first substrate carrying mechanism, a second substrate carrying mechanism, and an alignment mechanism, wherein each mechanism is provided in different diametrically sealed chambers, which each includes at least one of the gas applying mechanism and a gas exhausting mechanism.

Due to their dependency, claims 3-5, 12, 14, and 15 are necessarily allowable.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably Art Unit: 2879

accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Contact Information

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Joseph L. Williams whose telephone number is (571) 272-2465. The examiner can normally be reached on M-F (6:30 AM-3:00 PM).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nimeshkumar D. Patel can be reached on (571) 272-2457. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Joseph L. Williams Primary Examiner Art Unit 2879